

FORM 1449\*

## INFORMATION DISCLOSURE STATEMENT

IN AN APPLICATION

(Use several sheets if necessary)

Docket Number:

13041.14US01

Application Number:

09/866180

Applicant: Isao MATSUMOTO

Filing Date: 24 May 2001

Group Art Unit: 1745

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
W	5,840,441	Nov 1998	Hirofumi et al.	1	1	

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

W		Ikoma et al., "Self-Discharge Mechanism of Sealed-Type Nickel/Metal-Hydride Battery," <i>Journal of the Electrochemical Society</i> , Vol. 143, No. 6 (June 1996). ✓
		Matsumoto et al., "Ni-Fe Battery," extended abstract from ECS Detroit Meeting (1982). ✓
		Ikoma et al., "Study on Self-Discharge of a Metal Hydride Rechargeable Battery System Employing $MmNi_{5-x}M$ Alloy," extended abstract from 174th Chicago (Fall) Meeting (1988). ✓
		Yuasa et al., "Study on a Charge Characteristics of a Nickel/Hydride Battery System," extended abstract from 178th Seattle (Fall) Meeting (1990). ✓
		Fujiwara et al., "Development of a Hydrogen Absorbing Alloy for the Negative Electrode of Sealed Nickel-Hydride Battery System," extended abstract from 180th Phoenix (Fall) Meeting (1991). ✓
		Matsumoto et al., "A Sealed Ni/MH Battery System for EV," extended abstract from 183rd Honolulu (Spring) Meeting (1993). ✓
		Matsumoto et al., "Foamed Nickel Positive Electrode for a High Performance Cylindrical Ni-Cd Battery," <i>Power Sources 12</i> , pp. 203-220 (1988). ✓
W		Ogawa et al., "Metal Hydride Electrode for High Energy Density Sealed Nickel-Metal Hydride Battery," <i>Power Sources 12</i> , pp. 393-410 (1988). ✓



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PATENT TRADEMARK OFFICE

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.